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2877

# FACSIMILE TRANSMITTAL SHEET PLEASE DELIVER ASAP

3/15/01 4	:00 PM			
To: Box AF - Examiner Hoa Pham			FRO	PM: Elaine C. VonSpreckelsen
CC:				
COMPANY: US Patent Office		<b>Docket No.</b> 7009/018CP		-
FAX NUMBE 1-703-308				
PHONE NUM 1-703-308				
RE: Serial No. 09/296,928			TOI	AL PGS INCLUDING COVER: 8
<b>⊠URGENT</b>	⊠FOR REVIEW	PLEASE COM	MENT	□PLEASE REPLY

#### **NOTES/COMMENTS:**

DATE:

Patent Application of: Cerni et al.

Serial No.: 09/296,298

Docket No.: 7009/018CP

Filed: 22-Apr-1999

Attached is a Request For Reconsideration, Amendment and Remarks (7 pages) FAX COPY RECEIVED

Elaine C. Va Spuchelan

MAR 1 5 2001 **TECHNOLOGY CENTER 2800** 

Elaine C. VonSpreckelsen Secretary to Carl A. Forest

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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No.: 09/296,928

Group Art Unit:

2877

Filed: April 22, 1999

Examiner:

Pham, H.

For:

Chemical Mechanical Planarization

(CMP) Slurry Quality Control Process And Particle Size Distribution Measuring)

**Systems** 

Docket No.: 7009/018CP

Inventors:

Cerni et al.

**CERTIFICATE OF TRANSMISSION UNDER 37 CFR 1.8** 

I hereby certify that this correspondence, along with all papers referred to as being transmitted, are being facsimile transmitted to Box AF, Assistant Commissioner For Patents, Washington, DC at Patent and Trademark Office Fax No. (703) 308-7722.

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# REQUEST FOR RECONSIDERATION

This Amendment and Remarks is responsive to the Office Action mailed February 7, 2001, and includes a summary of a telephone interview with the examiner on March 12, 2001.

### **AMENDMENT**

### Please amend claims 1 and 26 as follows:

1. (Twice Amended) A quality control process for detecting physical and/or chemical changes in a CMP slurry, comprising the steps of:

transmitting radiation through a flow of [a] an undiluted optically dense slurry as used in a chemical mechanical planarization (CMP) process, the radiation having one or more wavelengths;

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